



Temperature activated self-lubrication in CrN/Mo₂N nanolayer coatings

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ABSTRACT

CrN/Mo₂N multilayers were deposited and TEM, SEM, EDS, XPS and TGA studies were carried out. TEM studies show crystalline layers with sharp interfaces. TGA studies indicate that the CrN protects the underlying Mo₂N layers from oxidation. On varying the periodicity the hardness of the films are in the 20–30 GPa regime, within the rule of mixtures of its constituents. Friction tests at high temperature shows the films to have a temperature activated self lubrication mechanism. Similar friction tests in a near nitrogen atmosphere shows the same temperature activated lubrication mechanism operating with the friction being in a lower regime. MoO₃ is isolated as the predominant oxides phase that evolves from the surface and at temperatures in excess of 400 °C acts as an *in situ* lubricant.

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1. Introduction

Hard coatings for cutting tools have been in use for many decades, [1–6], and have evolved from the initial, simple nitride and oxide coatings (such as TiN and Al₂O₃) applied by CVD and PVD in the 1970s, to more complex, high-performance alloy nitrides (such as TiAlN) employed today. More recently, the interest in green manufacturing has spurred development of coatings for dry machining, [7–10]. If coatings can effectively tolerate high temperatures or can help to reduce them, then coolant usage can be reduced. If the friction level due to the cutting process can be minimized, then lubricant usage can be reduced along with power requirements. In an earlier study the authors [11] characterized the deposition conditions and bulk

properties of CrN and Mo₂N coatings and their multilayers. In this paper the intent is to describe our work to develop and characterize multilayered, CrN/Mo₂N coatings of different ratio and bi-layer periodicities. The intent is also to characterize the tribological behaviour of these coatings at high temperature and prove that CrN/Mo₂N coatings do form hard coatings that are self lubricating at high temperatures. It is proposed to use the materials in a nano-layered structure that will be hard, tough, adherent, and lubricious at the service temperature (<1000 °C). The basic system of CrN_x and MoN_x to form multi (nano)-layered coatings offers some advantages as a starting point. Cr(N) is suggested because of its excellent wear and oxidation resistance to about 800 °C, [12,13] and Mo(N) [14] because it is likely to oxidize at about 500 °C, forming its low friction oxide, MoO₃. The presumption is that the Mo-oxide will reduce the cutting friction and consequently, the heat generated by high-speed contact (relative to a coating without the Mo). Past research showed that plasma sprayed composites of Cr₂O₃ and MoO₃ benefit from the addition of MoO₃ and exhibit a reduction of sliding friction from ~.4–.5 at RT to ~.2 at 450 °C (self-mated or against Cr-plated discs) [15]. A schematic representation of the structure conceived as a self

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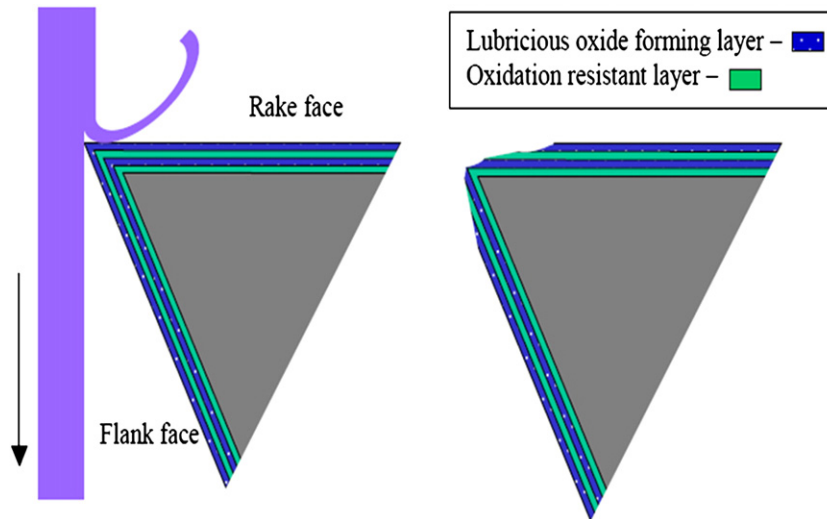


Fig. 1. Schematic representation of a cutting tool with multilayers. Alternating layers of the lubrication Mo_2N phase and the CrN phase.

lubricating tool is depicted in Fig. 1. This approach of using a lubricious oxide has also been explored by others in the cutting tool application, but they chose to explore TiO_x , [16,17], and VO_x , [18,19], as the active components. The oxide formation at temperatures above 400°C appears to offer promise for the approach. In our case, added characteristics of the selected materials are that they are both hard phases ($\sim 20\text{--}30$ GPa) and they are expected to be immiscible in their up to 800°C [20], this could result in the films retaining their layered structure (and strength) at temperatures exceeding 800°C .

2. Experimental details

The samples were prepared by sputter deposition in a closed-field dual-cathode unbalanced-magnetron system. The cryo-pumped system has a base pressure of 4×10^{-7} Torr and includes a high vacuum load lock

chamber. There are two vertically mounted $12.8\text{ cm} \times 40.6\text{ cm}$ planar magnetron cathodes facing each other on opposite sides of the substrate holder and 10 cm from the substrates. The hexagonal substrate holder is just large enough to eliminate the cross contamination from the other cathode. The substrate holder can be rotated at $5\text{--}15.2$ rpm to produce nano-layered materials with controlled layer thickness. All coatings were $1\text{--}1.5\ \mu\text{m}$ in total thickness. The substrates were single crystal Si (001), glass slides, and polished M50 tool steel discs ($R_a \sim 10\text{ nm}$). Sapphire substrates were used in cases where high temperature anneals were to be carried out. Prior to deposition, the samples were cleaned in an ultrasonic bath of methanol. High purity N_2 (99.99%) and Ar (ultra high purity) were used during the deposition process.

To analyze the chemical composition, XPS analysis was performed on the wear debris with an Omicron ESCA probe, which was equipped with an EA125 energy analyzer. Photoemission was stimulated by a monochromated Al K-alpha X-ray (1486.6 eV) with an operating

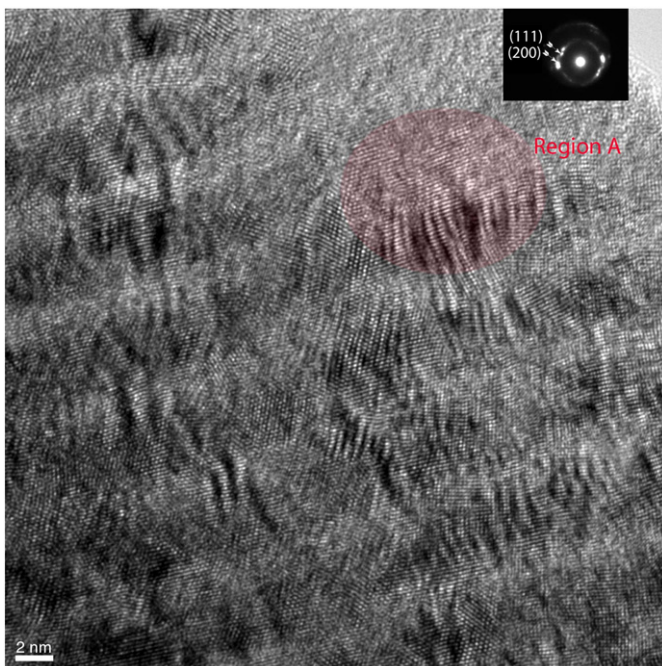


Fig. 2. Cross-section TEM micrograph of the multilayers in bright field mode. The mild contrast is due to the different phases present as well as local strains and variations in lattice orientation with respect to beam direction. The lattice ordering is also visible showing a continuity across layer boundaries (area A).

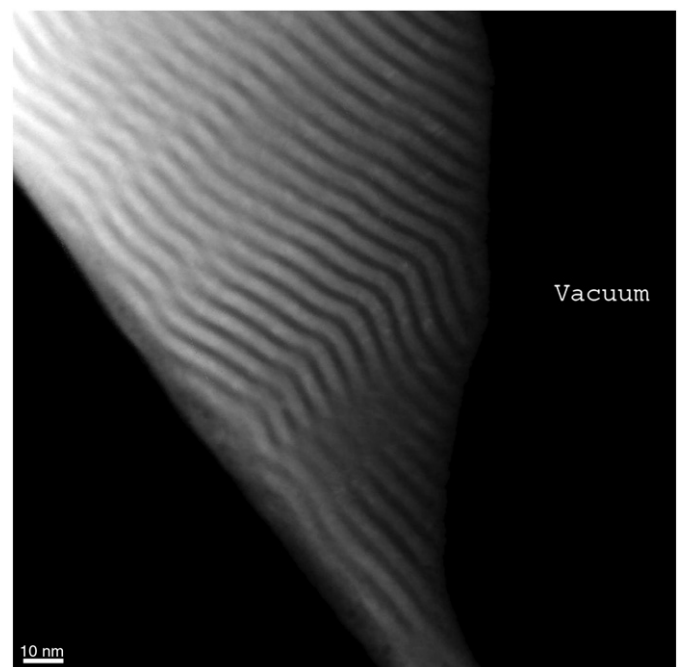


Fig. 3. Cross-section STEM micrograph of the multilayers. The sharp bright and dark contrast is due to the difference in atomic number. The brighter regions are from the heavier element (Mo) which has a high scattering angle.

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